

METHOD FOR LATERAL TRIMMING OF SPACERS

Allison Holbrook

Jiahua Huang

Sunny Cherian

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ABSTRACT

Spacer etch trim techniques are provided. The method controllably trims a multi-film stack spacer utilizing a self-limiting etch technique. The method may use a dry etch etcher with low bias power. The dry etch process may also use other 10 modified parameters, such as gas flows and various pressures.